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U.S. Denartment of Commerce, Patent and Trademark Office	Application No.:	09/974,571
JAN 0 5 2004  JAN 10 5 2004  JAN 10 5 2004  (Use several sheets if necessary)	Filing Date:	October 9, 2001
	First Named Inventor:	Peter G. Borden
JAN U J 2334	Group Art Unit:	2877
INFORMATION DISCLOSURE STATEMENT BY APPLICANT	Examiner Name:	Unknown
	Confirmation No.:	1003
	Attorney Docket No.:	BOX013 US

			U.S. Pa	tent Documents			
*Examiner Intials		Document Number	Date	Name	Class	Subclass	Filing Date if Appropriate
ad	1.	4,273,421	6/16/81	Gurtler	356	432	
B	2.	4,854,710	8/8/89	Opsal et al.	356	432	
<b>1</b> 00	3.	4,211,488	7/8/80	Kleinknecht	356	433	
· PD	4.	5,379,109	1/3/95	Gaskill et al.	356	445	
120	5.	6,489,801	12/3/02	Borden et al.	324	766	
· 120	6.	5,966,019	10/12/99	Borden	324	752	
PD	7.	5,377,006	12/27/94	Nakata	356	349	
PD	8.	5,706,094	1/6/98	Maris	356	432	
100	9.	6,118,533	9/12/00	Banet et al.	356	345	
Dal	10.	6,323,951	11/27/01	Borden et al.	356	502	
MO	11.	6,426,644	7/30/02	Borden et al.	324	765	
120	12.	4,952,063	8/27/90	Opsal et al.	356	432	
DCI	13.	5,042,952	827/1991	Opsal et al.	356	432	
MO	14.	5,159,412	10/27/92	Willenborg et al.	356	445	
<i>D</i> 0	15.	5,181,080	1/19/93	Fanton et al.	356	381	
130	16.	5,228,776	7/20/93	Smith et al.	374	5	
920	17.	4,255,971	3/17/81	Rosencwaig	73	606	
jes	18.	4,579,463	4/1/86	Rosencwaig et al.	374	57	
120	19	4,632,561	12/30/86	Rosencwaig et al.	356	432	
13	20.	4,636,088	1/13/87	Rosencwaig et al.	374	5	
13	21.	4,750,822	6/14/88	Rosencwaig et al.	324	445	
jes	22.	4,513,384	4/23/95	Rosencwaig	364	563	
S	23.	6,049,220	4/11/00	Borden et al.	324	765	
Po	24.	6,483,594	11/19/02	Borden et al.	356	502	
حرا	25.	5,652,716	7/29/97	Battersby	703	13	

Examiner: Date Considered: 6/10/04

<sup>\*</sup> Examiner: Initial if reference is considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication with applicant.

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EM	26.	5,761,082	6/2/98	Miura-Mattausch	703	14	
129)	27	4,996,659	2/26/91	Yamaguchi et al.	714	736	
BD	28.	6,154,280	11/2/00	Borden	356	376	
130	29.	6,054,868	4/25/00	Borden et al.	324	752	
13	30.	5,883,518	3/16/99	Borden	324	752	
2	31.	5,877,860	3/2/99	Borden	356	376	
· 10	32.	4,652,757	3/24/87	Carver	250	360	
13	33.	5,978,074	11/2/99	Opsal et al.	356	72	
B	34.	6,211,961	4/3/03	Maris	356	432	
m	35.	6,268,916	7/31/01	Lee et al.	356	432	
M	36.	6,169,601	1/2/01	Eremin et al.	356	240	
100	37.	2002/0126732A1	9/12/02	Shakouri et al.	374	130	•
on	38.	4,201,087	5/6/80	Akita et al.	73	339	
Col	39.	2003/96436A1	5/22/03	Satya et al.	438	11	
M	40.	6,486,965	11/26/02	Kim	356	626	
PO	41.	5,741,614	4/21/98	McCoy et al.	430	30	
50	42.	6,327,035	12/4/01	Li et al.	356	432	
m	43.	5,454,004	9/26/95	Leger	372	99	
CA	44.	6,281,027	9/28/01	Wei et al.	438	14	
120	45.	4,521,118	06/00/85	Rosencwaig	374	5	
M	46.	5,074 669	12/1/91	Opsal	356	447	
B	47.	5,764,363	6/9/98	Ooki et al.	356	364	
13	48.	5,657,754	8/19/97	Rosencwaig	128	633	
932	49	4,634,290	1/6/87	Rosencwaig	374	5	
13	50	4,552,510	6/11/85	Rosencwaig	374	7	
M	51.	4,571,685	02/18/86	Kamoshida	364	468	

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روم	52.	99/94880	12/16/1999	PCT	G01R	31/26			
Cal	53	00/07357	3/20/2000	PCT	GOIL	21/17			
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Cal .	54.	Rosencwaig et al. 1985, pp1013-101.		al Waves Through Option	al Reflectance'	, Appl Phys.	Lett. 46,	June	
·M	55.	Rosencwaig, "The	rmal-Wave Imaging"	, SCIENCE, Volume 2	8, No. 4569, O	ct. 1982, pp.2	23-228		
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PO	59.		Ion Implant Monitorin 321, (1987), 537-541.	ng With Thermal Wave T	echnology," Nu	clear Instrume	nts and N	∕lethods	
רמ	60.		oustic and Phototherm	e Measurements and Ima al Phenomena II, Spring		_			
900	61.			ts and Thermal Wave Mo Quantitative Nondestruct					
دوم	62.	Quality Today No		"In-Line Metrology St http://www.qualitytoda					
910	63.			, "Surface Measuremen , SPIE vol. 816, August			arski-Pro	ofiling	
98	64.	"Process Monitori	ng System", Quantox	Product Brochure, 3 pa	ges, published	prior to Marc	h 1, 200	2	
m	65.	A. Rosencwaig, "7 pp.182-191	Thermal Wave Measu	rement of Thin-Film Th	nickness", 1986	American C	hemical	Society,	
M	66.	October 1983, pp.	C6-483 - C6-489	ness Measurements wit					
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Examiner:	Durand	Date Considered: 6/10/14
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· PO	73.	A. Rosencwaig, "Applications of Thermal-Wave Physics to Microelectronics", VLSI Electronics, Microstructure Science Vol. 9, 1995, pp 227-288
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B	76.	W. Lee Smith, "Nondestructive Thermal Wave Imaging of Voids & Microcracks in Aluminum Metallization", 1989 WLR Final Report, pp 55-68
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(a)	81:	L. Chen et al., "Thermal Wave Studies of Thin Metal Films and Structures", (believed to be prior to March 1, 2002)
900	82.	R. S. Sharpe, "Research Techniques in Nondestructive Testing Vol. VII, Academic Press 1984, pp 158-365
Pos	83.	R. L. Thomas et al., "Thermal Wave Imaging For Nondestructive Evaluation" 1982 Ultrasonic Symposium, pp 586-590
99	84.	G. Slade Cargill III, "Electron-Acoustic Microscopy", Physics Today, October 1981, pp 27-32
P	85.	A. Rosencwaig, "Thermal Wave Microscopy", Solid State Technology, March 1982, pp 91-97
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Examiner: Dury Obord	Date Considered: 6/10/04
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				Sheet 1 of 1
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	TR 2 3 2004 W	First Named Inventor:	Peter G. Borden	
•		Group Art Unit:	2877	
<b>V</b>	Use several sheets if necessary)	Examiner Name:	Smith, Zandra B.	
	(Use several sheets if necessary)	Confirmation No.:	1003	
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			U.S. Pa	itent Documents				
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725	1.	2001/0015937	8/23/01	Yamaguchi et al.	369	13		
100	2.	6,020,964	2/1/00	Loopstra et al.	356	500		
190	3.	6,400,454	6/4/02	Noguchi et al.	356	237		
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		Other Art	(Including Autho	or, Title, Date, Pertinent Pag	es, Etc.)		l	<u>.l</u>
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